Response under 37 C.F.R. 1 - Expedited Examining Procedure -Examining Group 1763



Customer No. 01333

<u>IN THE UNITED STATES PATENT AND TRADEMARK OFFICE</u>

In reApplication of: TRAISTE En A. Van Slyke, et al

> THERMAL PHYSICAL VAPOR DEPOSITION SOURCE FOR MAKING AN ORGANIC LIGHT-EMITTING **DEVICE**

Serial No. US 09/996,415

Filed 28 November 2001

Commissioner for Patents Washington, D.C. 20231

Group Art Unit: 1763

Examiner: Richard R. Bueker

Service as first class mail in an envelope addressed

Paula West

SEP 3-0 2002 TC 1700

Transmitted herewith is an amendment in the above-identified application:

No additional fee is required.

The f	fee has been calculated as shown below: OTHER THAN A SMALL					
	(Col. 1)		(Col. 2)	(Col. 3)	ENTITY	
	CLAIMS REMAINING AFTER AMENDMENT		* HIGHEST NO. PREVIOUSLY PAID FOR	PRESENT EXTRA	RATE	ADDITIONAL FEE
TOTAL	18	MINUS	20	0	X 18	\$ 0
INDEP	2	MINUS	3	0	X 84	\$0
FIRST PRESENTATION OF MULTIPLE DEPENDENT CLAIM					+ 280	\$ 0
					TOTAL	\$0

* The "Highest Number Previously Paid For" (Total or Independent) is the highest number found from the equivalent box in Col. 1 of a prior amendment or the number of claims originally filed.

Please charge my Eastman Kodak Company Deposit Account No. <u>05-0225</u> in the amount of

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The Commissioner is hereby authorized to charge payment of the following fees associated with this communication or credit any overpayment to Eastman Kodak Company Deposit Account No. 05-0225

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Any additional filing fees required under 37 CFR 1.16.

Any patent application processing fees under 37 CFR 1.17. (For Extensions of Time and other Petitions to the Assistant Commissioner)

Raymond L. Owens/phw Telephone: (585) 477-4653 Facsimile: (585) 477-4646

Attorney for Applicants Registration No. 22,363



Response under 37 C.F.R. 1.116 - Expedited Examining Procedure Examining Group <u>1763</u>

BOX AF 83401RLO

Customer No. 01333

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Application of:

Steven A. Van Slyke, et al

THERMAL PHYSICAL VAPOR DEPOSITION SOURCE FOR MAKING AN ORGANIC LIGHT-EMITTING DEVICE

Serial No. US 09/996,415

Filed 28 November 2001

5 Commissioner for Patents Washington, D.C. 20231

Sir:

Group Art Unit: 1763

Examiner: Richard R. Bueker

I hereby certify that this correspondence is being deposited today with the United States Postal Service as first class mail in an envelope addressed to Commissioner for Patents, Washington, D.C. 20231.

Paula West

Date

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RESPONSE UNDER 37 CFR 1.116

In response to the Office Action mailed July 8, 2002, please amend the above-identified application as follows, without prejudice.

In the Claims:

Please amend Claim 1 as set forth below:

1. (once amended) A thermal physical vapor deposition source for vaporizing solid organic materials and applying a vaporized organic material as a layer onto a surface of a structure in a chamber at reduced pressure in forming an organic light-emitting device (OLED), comprising:

a) a bias heater defined by side walls and a bottom wall, the side walls having a height dimension H_B ,

b) an electrically insulative container disposed in the bias heater, the container receiving solid organic material which can be vaporized, the container defined by side walls and a bottom wall, and the container side walls

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